

EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1889	(219/390,444.1,468.1).CQLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/12/07 07:13
L2	4086	(118/725,728).CQLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/12/07 07:13
L3	221	((L1 L2) and ((thermal\$3 heat) adj (process\$3 treat\$4)) and (substrate wafer) and ((cover\$3 layer jacket shell coat\$3 shield \$3) near7 quartz))	US-PGPUB; USPAT; USOCR	OR	ON	2009/12/07 07:13
L4	1889	(219/390,444.1,468.1).CQLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/12/07 07:13
L5	4086	(118/725,728).CQLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/12/07 07:13
L6	569	((L4 L5) and ((thermal\$3 heat) adj (process\$3 treat\$4)) and (substrate wafer) and ((cover\$3 layer jacket shell coat\$3 shield \$3) with (support table stage (hot adj plate) susceptor chuck))	US-PGPUB; USPAT; USOCR	OR	ON	2009/12/07 07:13
L7	117	3 and L6	US-PGPUB; USPAT; USOCR	OR	ON	2009/12/07 07:13
L9	49	((L1 L2) and ((thermal\$3 heat) adj (process\$3 treat\$4)) and (substrate wafer) and ((rough roughness roughened roughening) near5 (cover\$3 layer jacket shell coat\$3 shield\$3 quartz))	US-PGPUB; USPAT; USOCR	OR	ON	2009/12/07 08:32
L10	22	((392/416,418).cqls. and ((thermal \$3 heat) adj (process\$3 treat\$4)) and (substrate wafer) and ((rough roughness roughened roughening) near5 (cover\$3 layer jacket shell coat\$3 shield\$3 quartz))	US-PGPUB; USPAT; USOCR	OR	ON	2009/12/07 09:22

L11	3	10 not 9	US-PGPUB; USPAT; USOCR	OR	ON	2009/12/07 09:23
L12	1	(((((thermal\$3 heat) adj (process \$3 treat\$4)) and (substrate wafer) and ((rough roughness roughened roughening) near5 (cover\$3 layer jacket shell coat\$3 shield\$3 quartz))))).clm.	US-PGPUB	OR	ON	2009/12/07 09:24
L13	3	((219/520,521,546,548).ocls. and (((thermal\$3 heat) adj (process \$3 treat\$4)) and (substrate wafer) and ((rough roughness roughened roughening) near5 (cover\$3 layer jacket shell coat\$3 shield\$3 quartz))))).clm.	US-PGPUB; USPAT; USOCR	OR	ON	2009/12/07 09:37
L14	0	((219/520,521,546,548).ocls. and (((thermal\$3 heat) adj (process \$3 treat\$4)) and (substrate wafer) and ((rough roughness roughened roughening) near5 (cover\$3 layer jacket shell coat\$3 shield\$3 quartz))))).clm.	US-PGPUB	OR	ON	2009/12/07 09:39

EAST Search History (Interference)

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12/ 7/ 09 9:39:46 AM**C:\ Documents and Settings\jpelham\ My Documents\ EAST\ workspaces\ 10.552267.wsp**